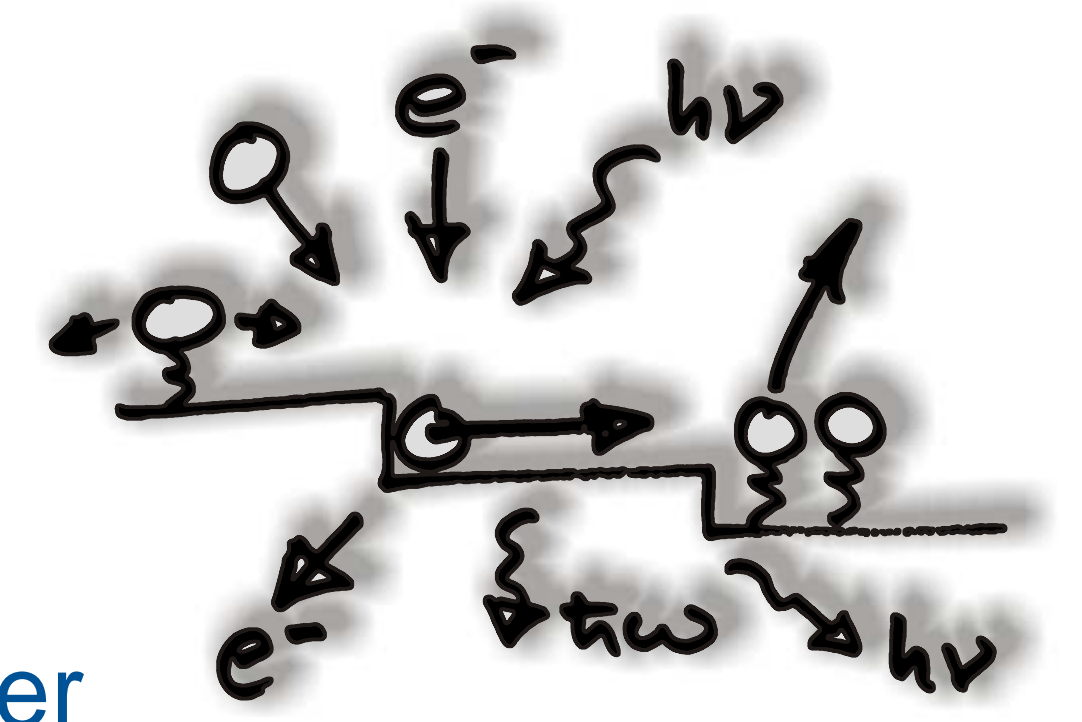


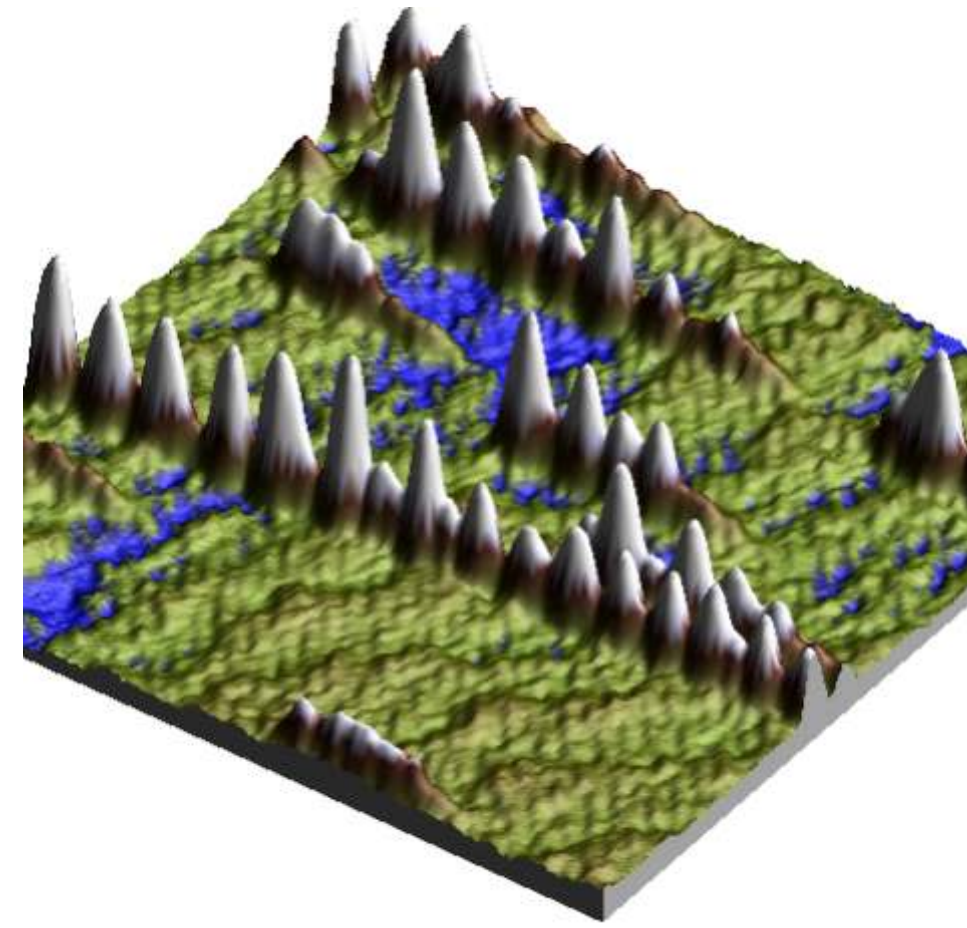
Creation of nanodots with swift heavy ions

Thorsten Peters, Miriam Klusmann, Ender Akcöltekin, Orkhan Osmani, Sevilay Akcöltekin, Henning Lebius, Marika Schleberger



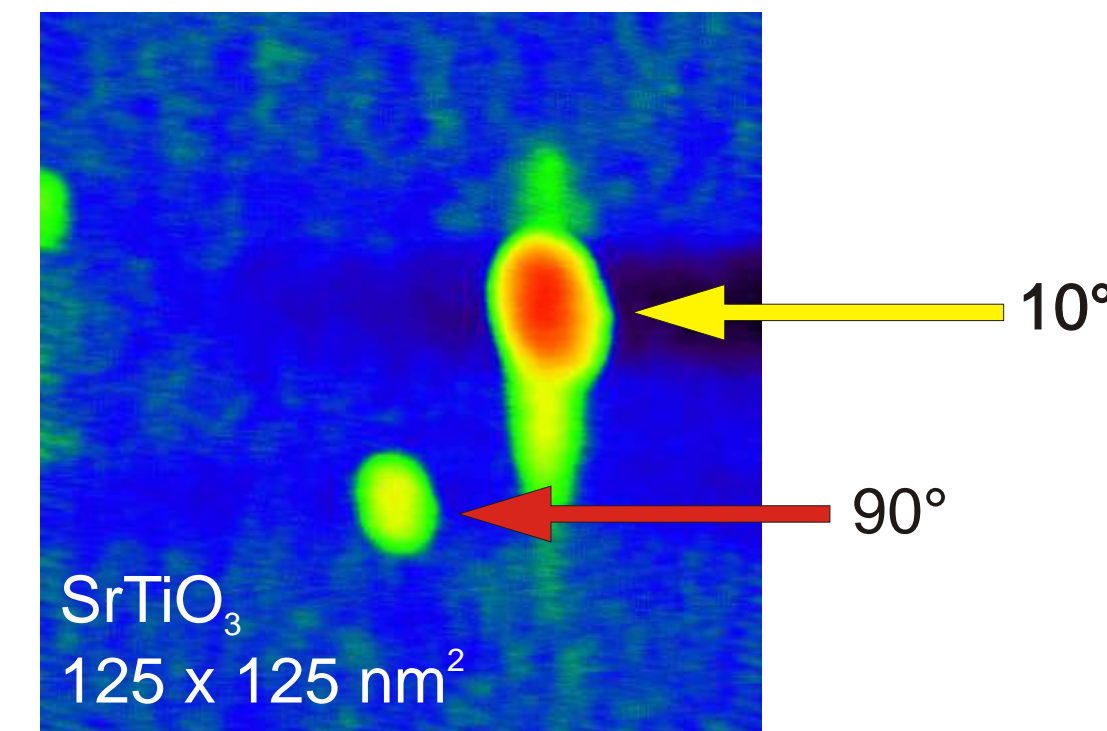
Goals

- Investigation of electronic excitations in the surface region of non-conducting solids
- Characterization of ion induced defects with scanning probe microscopy under UHV conditions
- Controlled modifications of oxide surfaces and thin film systems on the nanometer scale

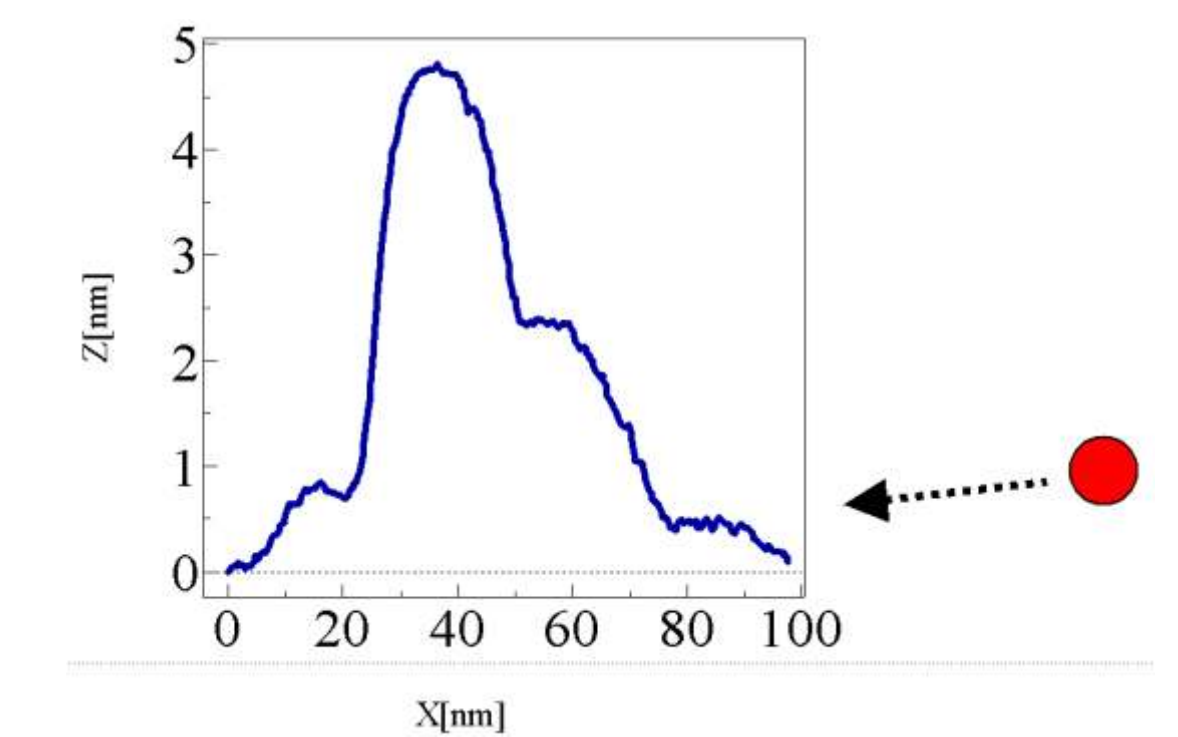


SrTiO₃:

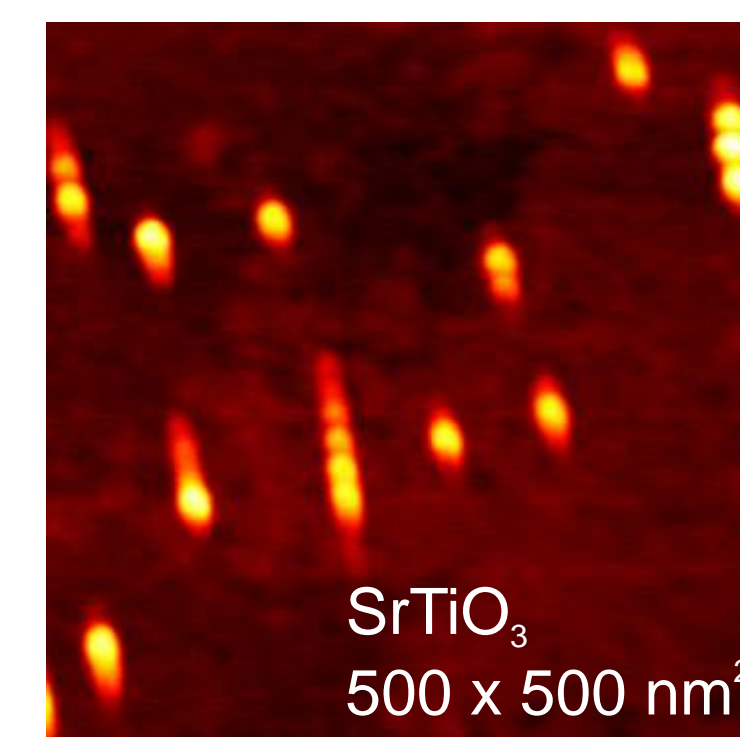
- Irradiation under 90° and 10°



- Round defects at vertical impact
- Elongated defects at glancing angle

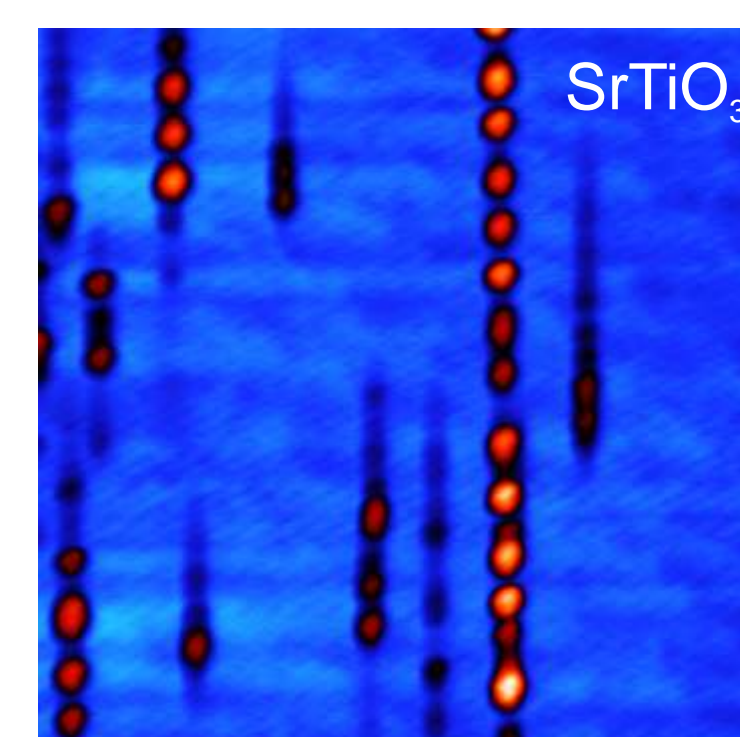
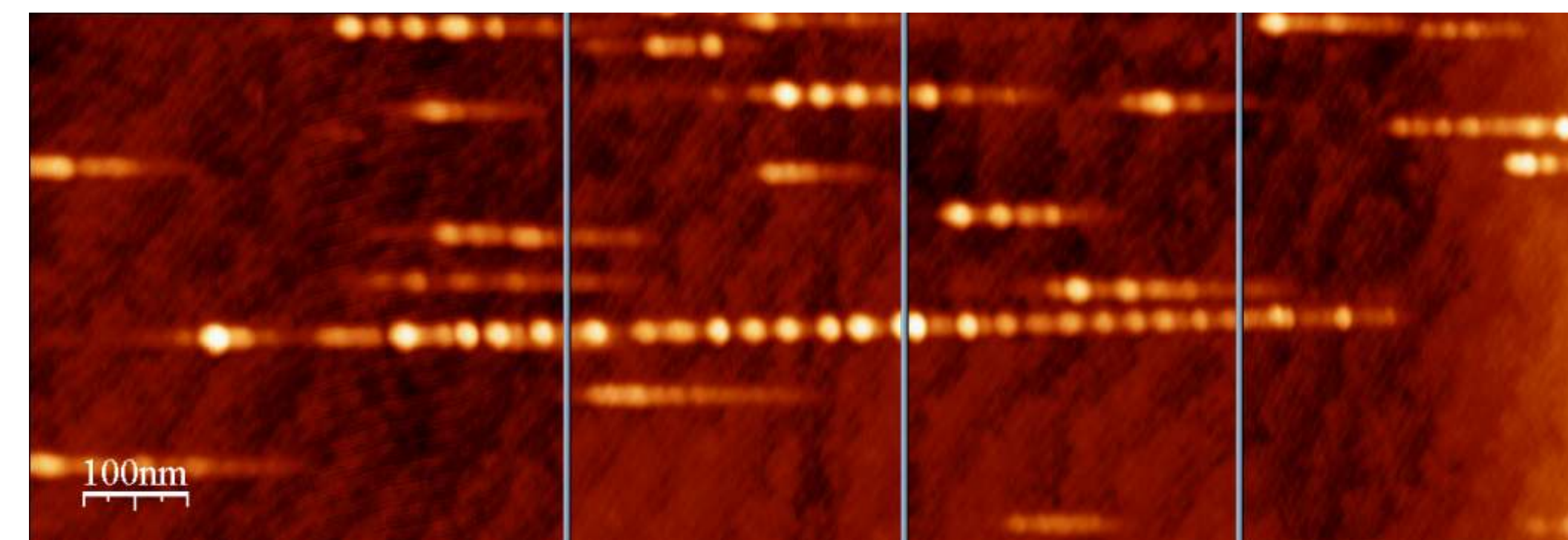


- Irradiation under 3° and 6°

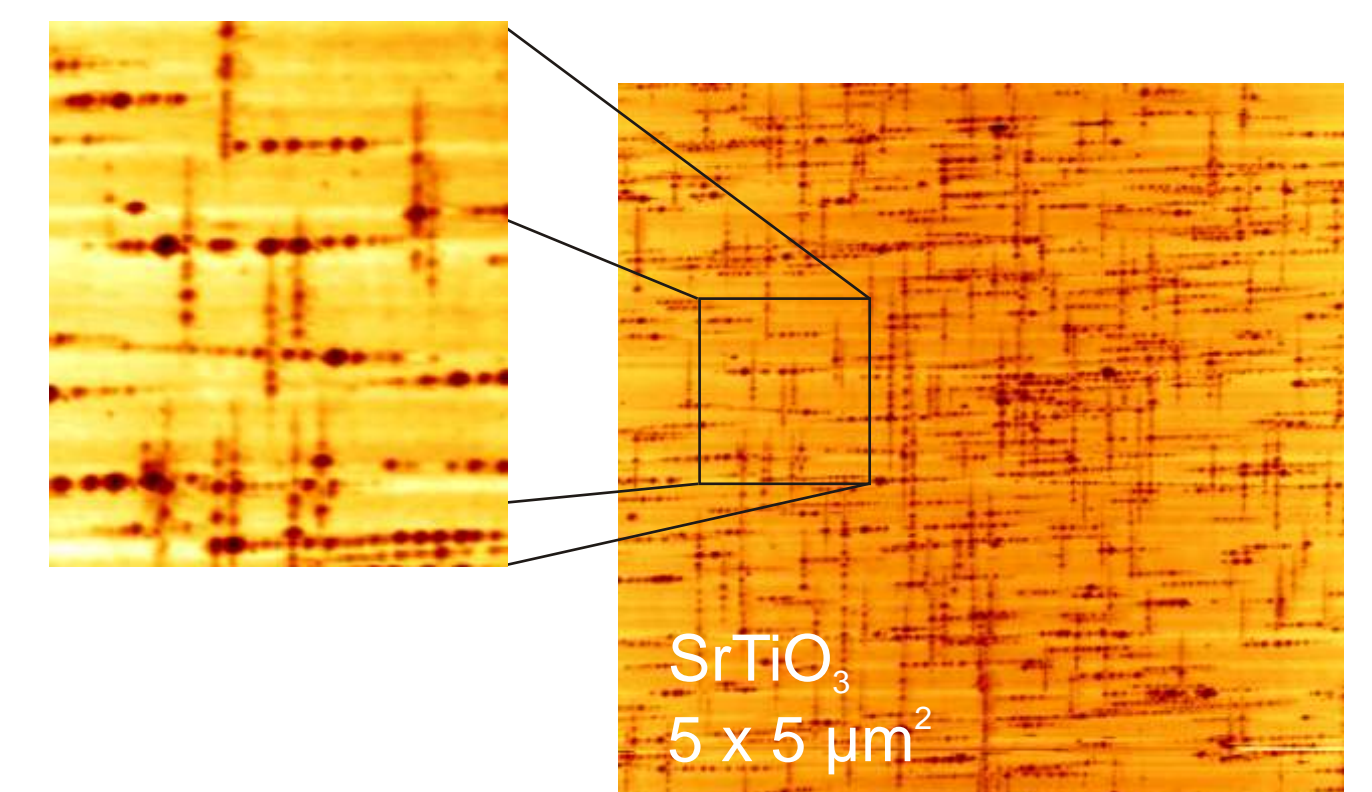


- The distance between hillocks increases with angle of incidence
- Critical angle ~ 5°
- Track length of more than a micron can be produced
- Hillocks within the chain are of equal height
- Hillocks appear on terraces as well as at step edges

- Irradiation under 1°

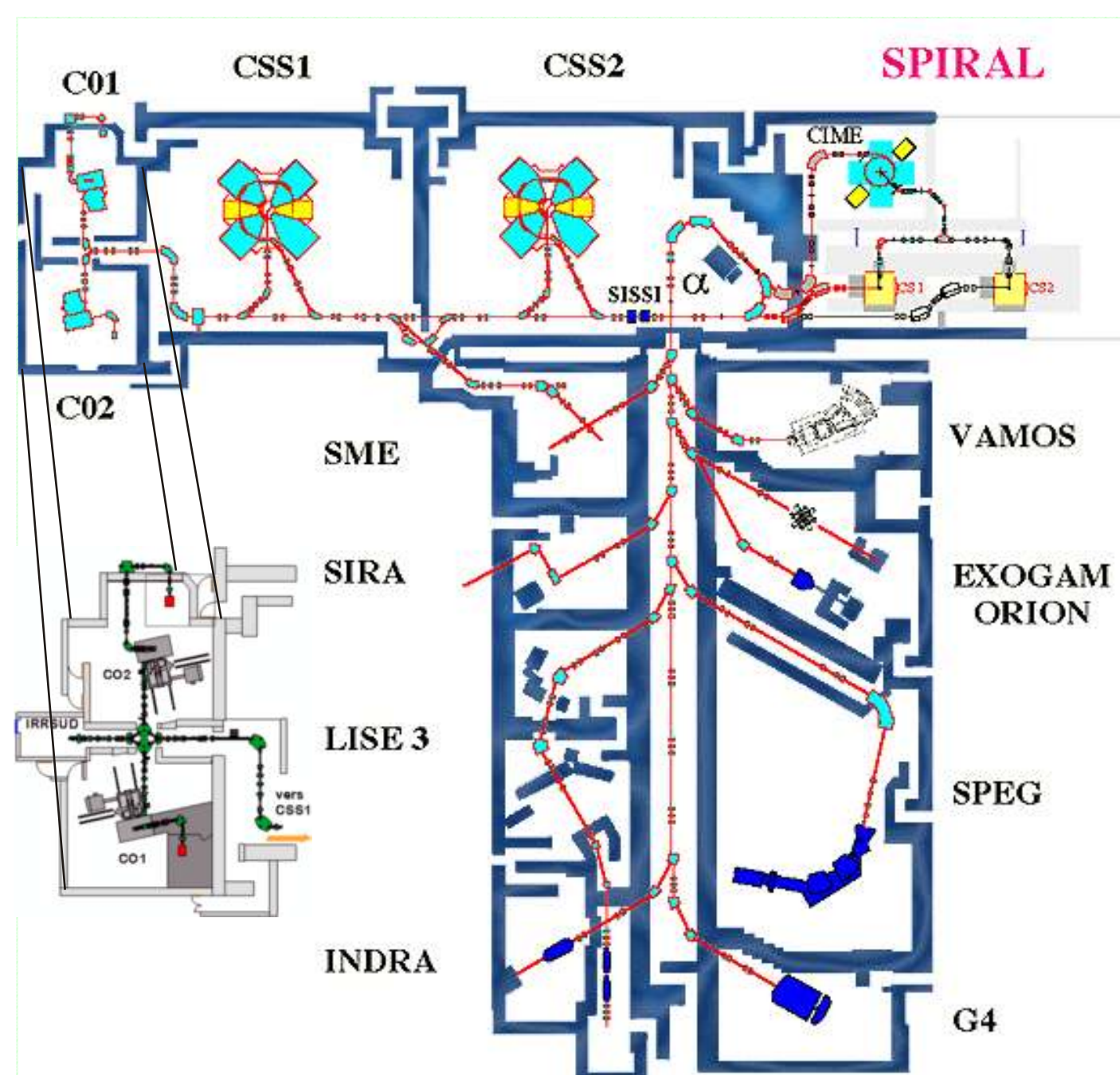


- A striking periodicity of hillocks is observed
- Criss-cross pattern of chains can be written



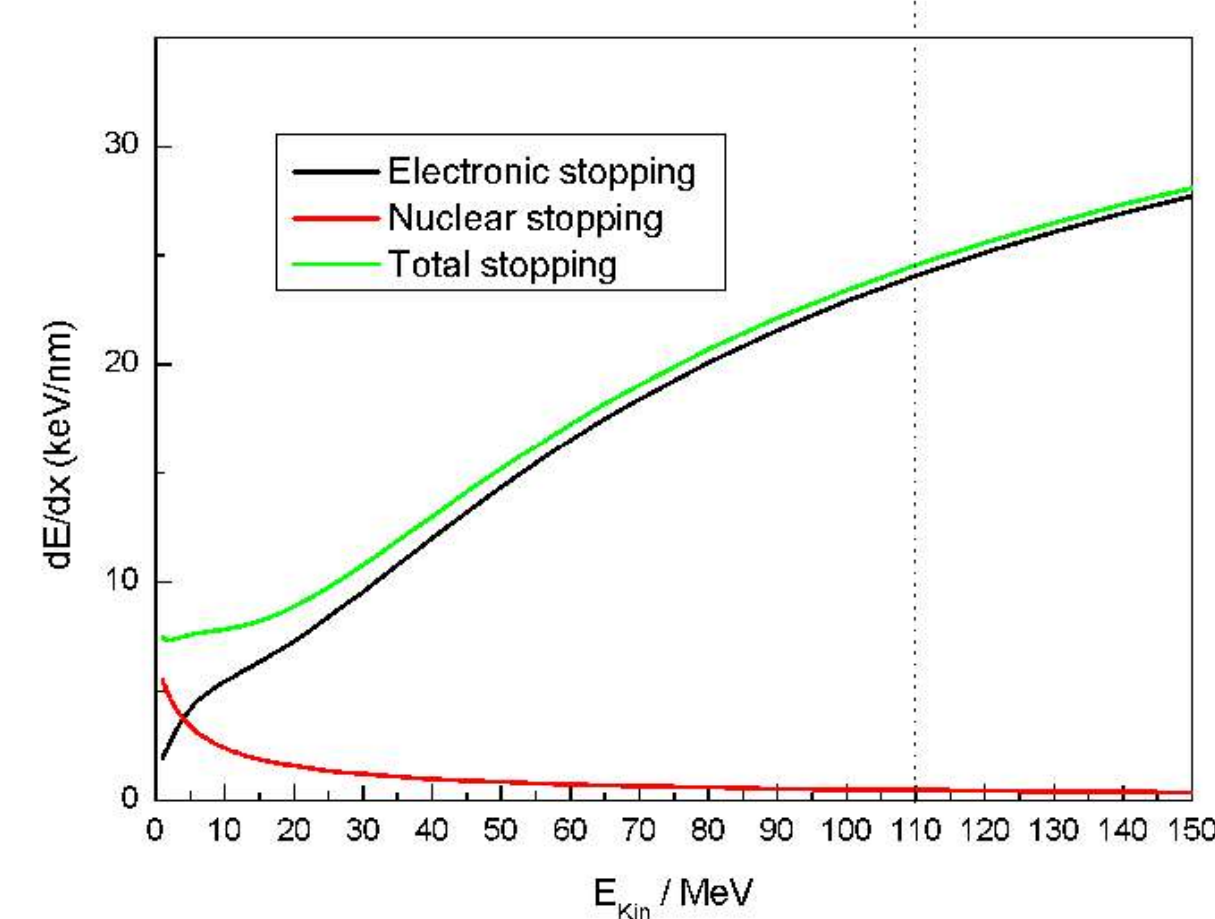
IRRSUD at GANIL

- ECR4-CO2:** ECR-source for the production of swift heavy highly charged ions. Acceleration in the cyclotron CO2.



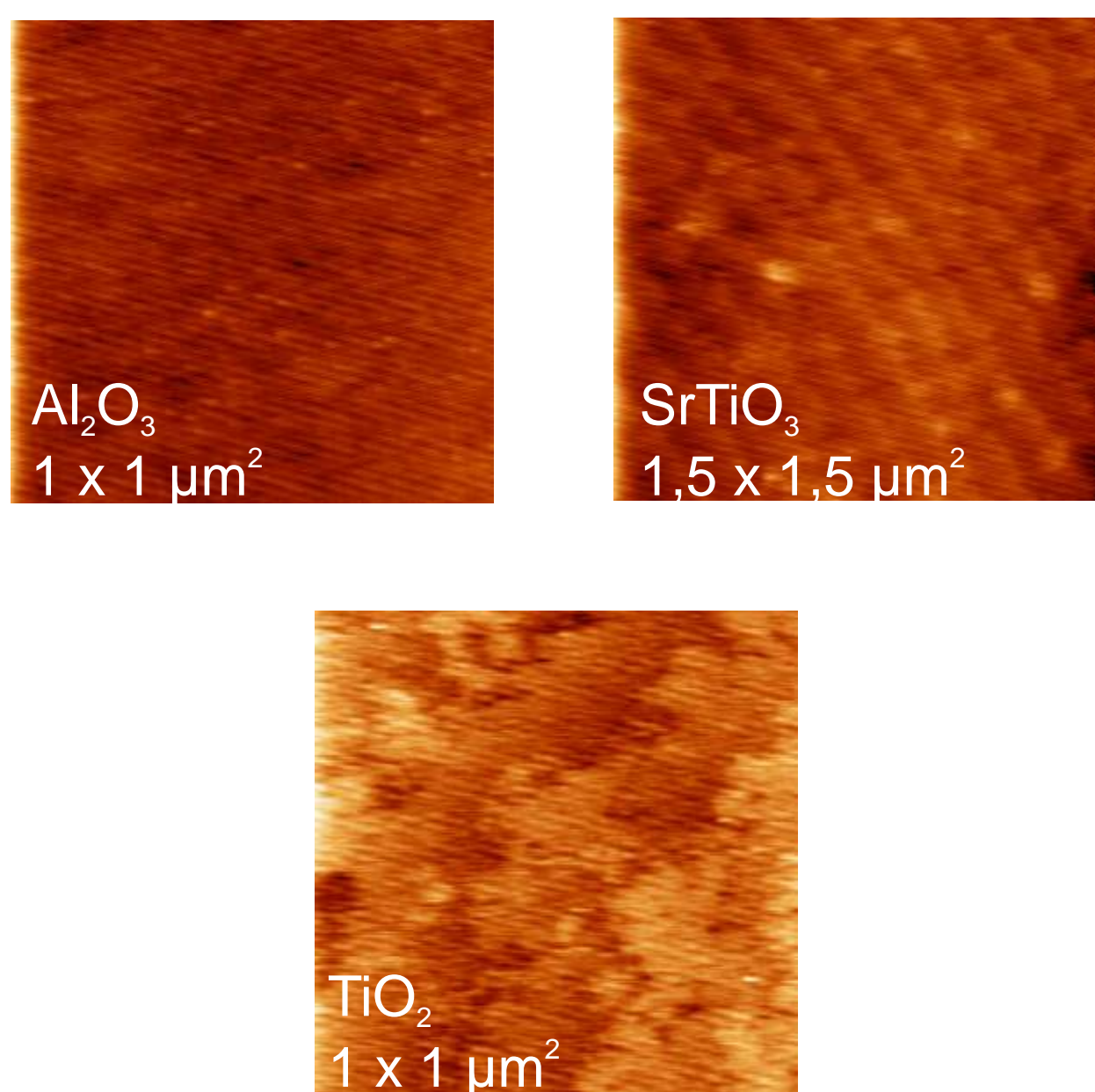
- Ions:** The energy loss can be varied by choosing the energy and the charge state. Depending on these parameters structural defects are produced that can be investigated by scanning probe methods.

- 0,521 MeV/u 208 Pb²⁸⁺:** The energy loss according to SRIM calculations is about 24 keV/nm for the oxide surfaces Al₂O₃, SrTiO₃ and TiO₂. The ions penetrate ca. 8 μm into the solid.

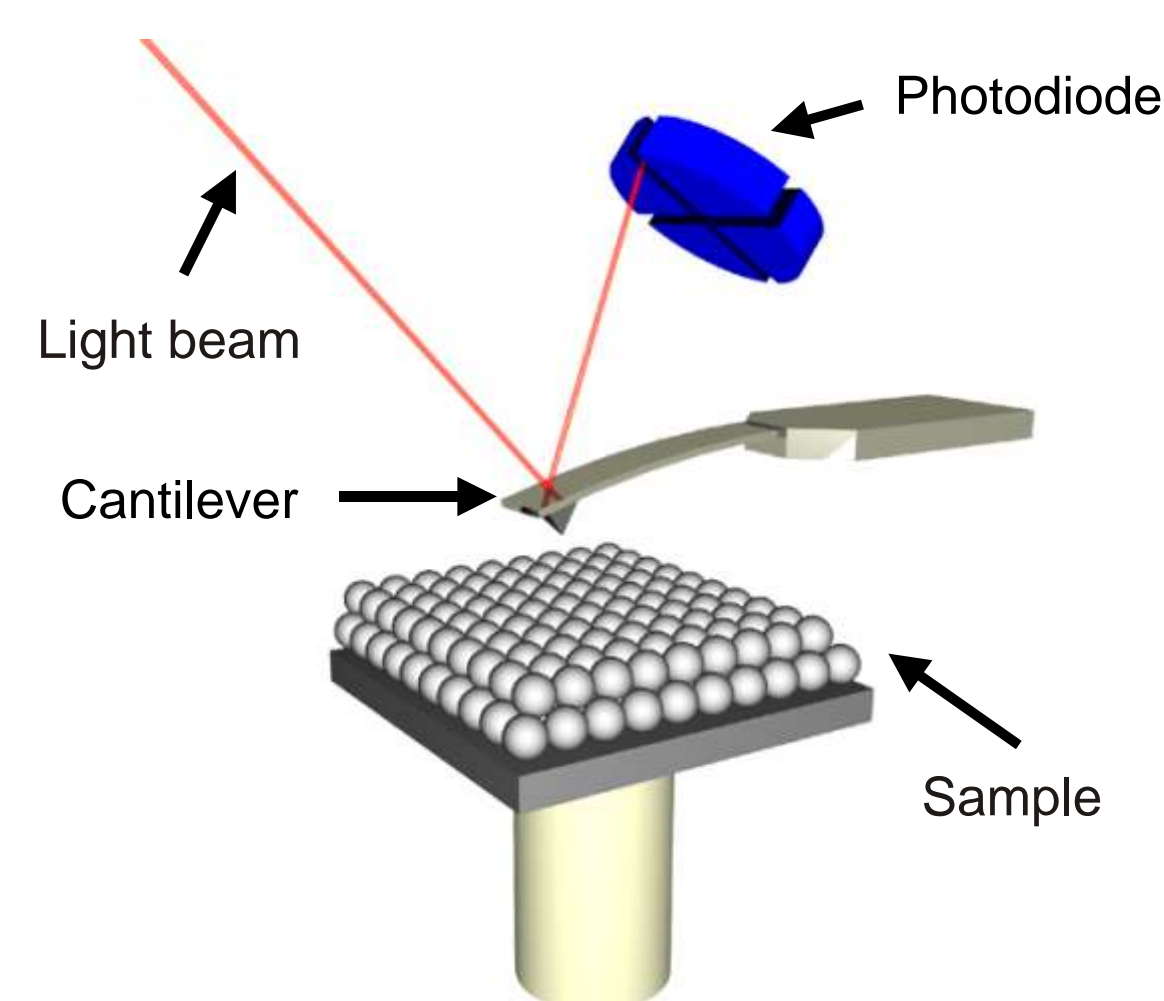


Analysis of defects

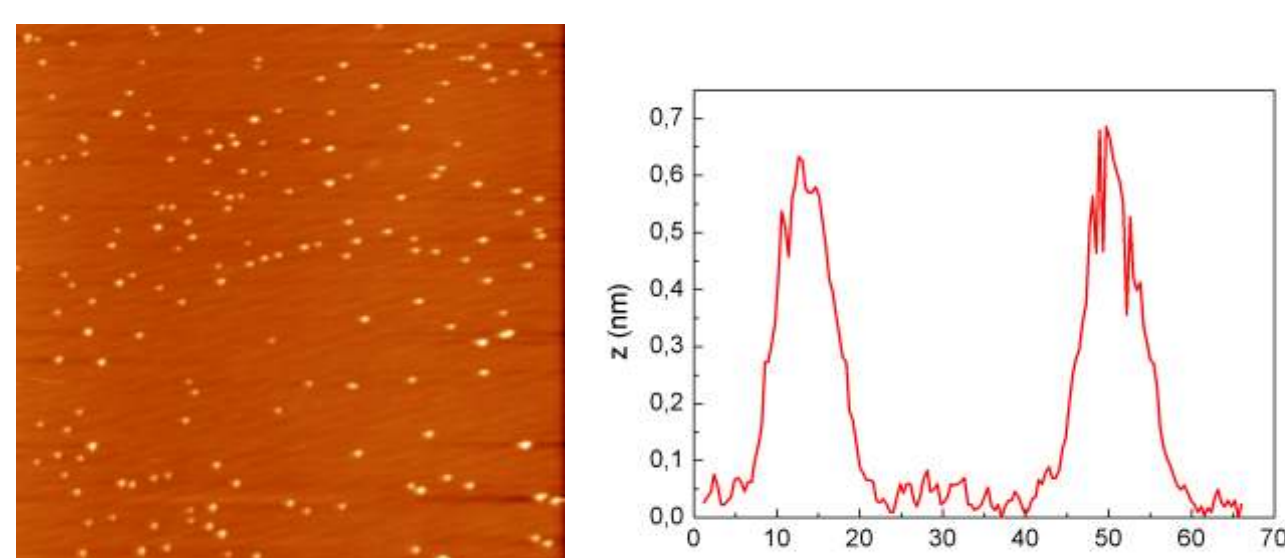
- Preparation:** Oxide surfaces are easily prepared ex-situ (acetone) and are extremely flat (rms < 0.2 nm). After introducing the samples into UHV terraces and steps can be easily resolved.



- Contact and non-contact mode:** Number, shape and type of defects are recorded with different measurement techniques. The non-contact mode allows a non-destructive measurement also of soft structures



- Topography after irradiation with 4 x 10⁹ ions/(cm² s). The fluence is low enough so that the impacts do not overlap.

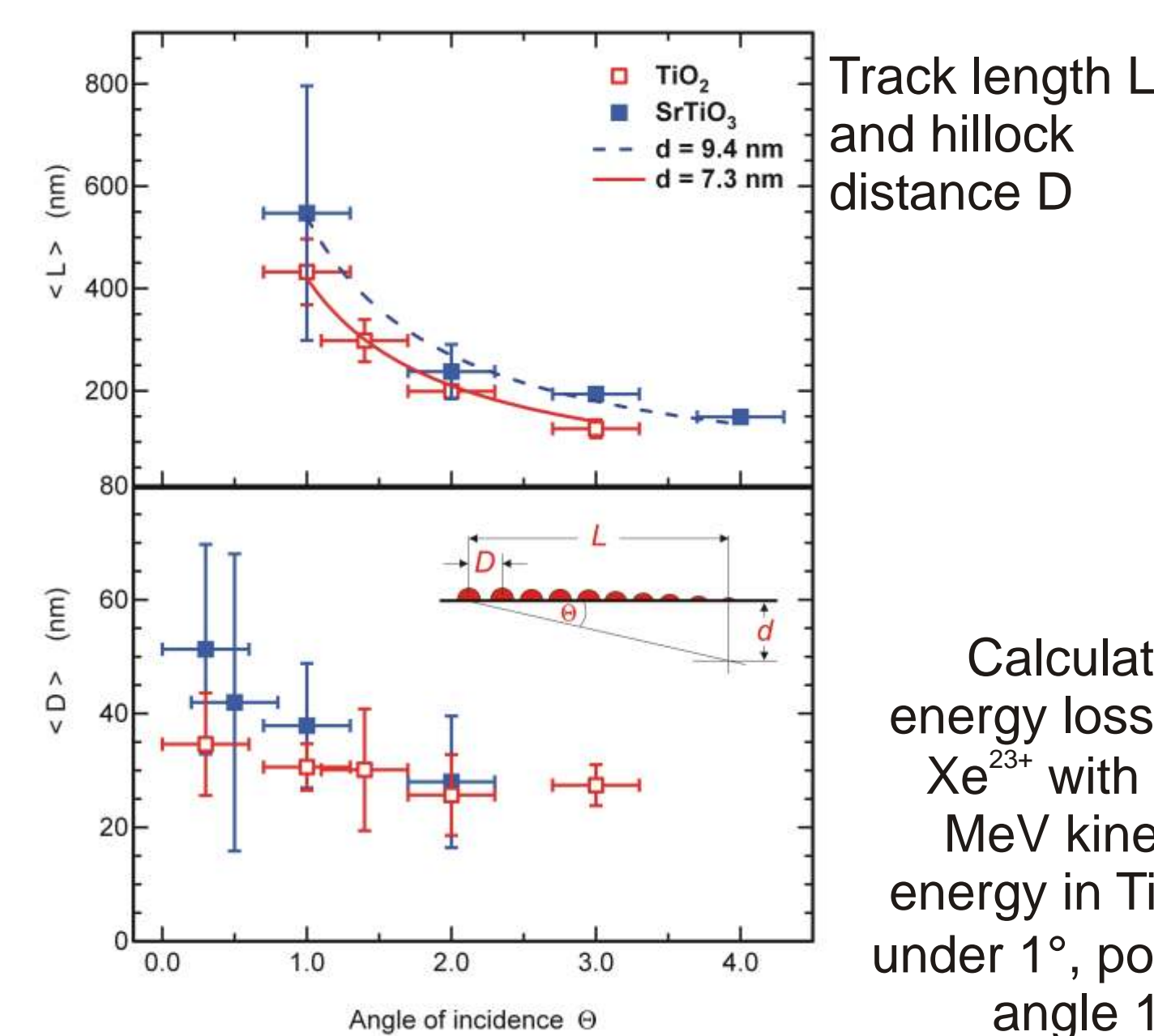


- Hillocks are created - no craters
- One defect per ion
- Height ranging from 1 to 5 nm
- Diameter (FWHM) ca. 15 nm (limited by tip radius)
- Mechanically hard
- Stable in time

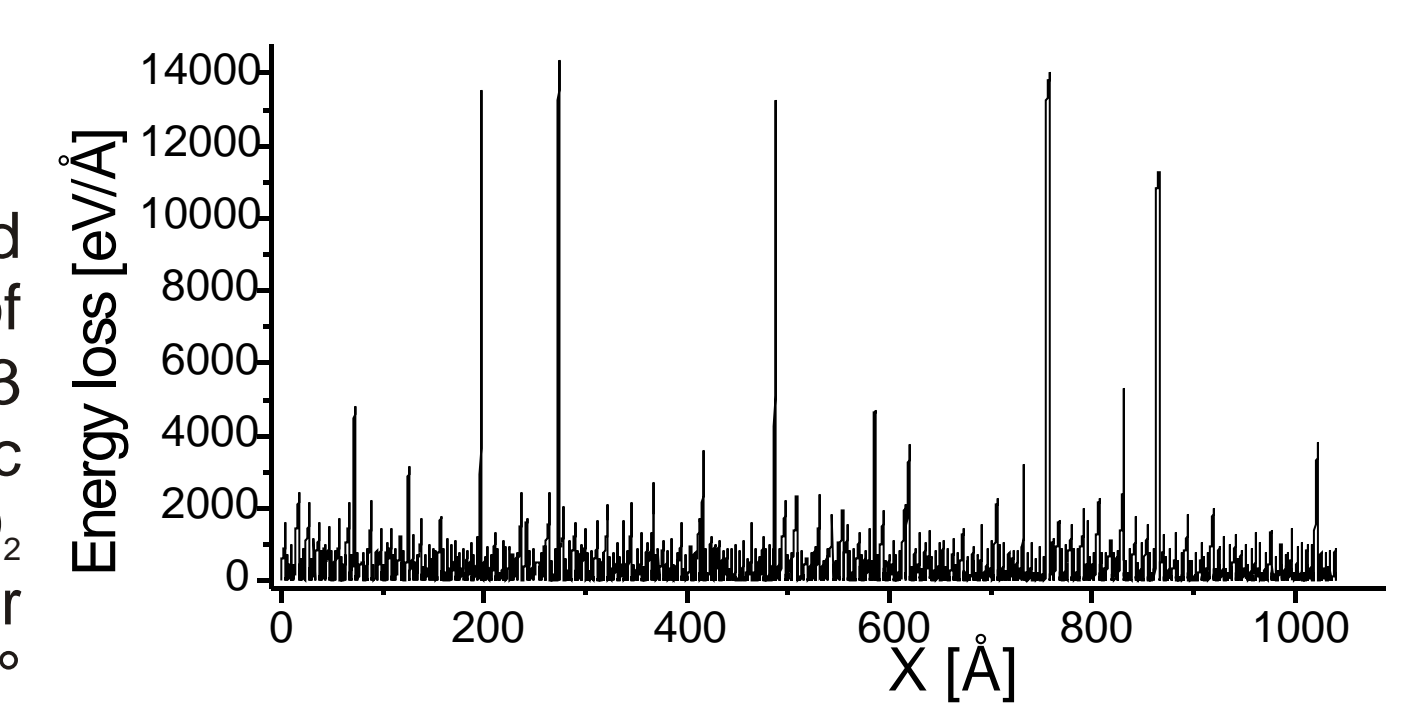
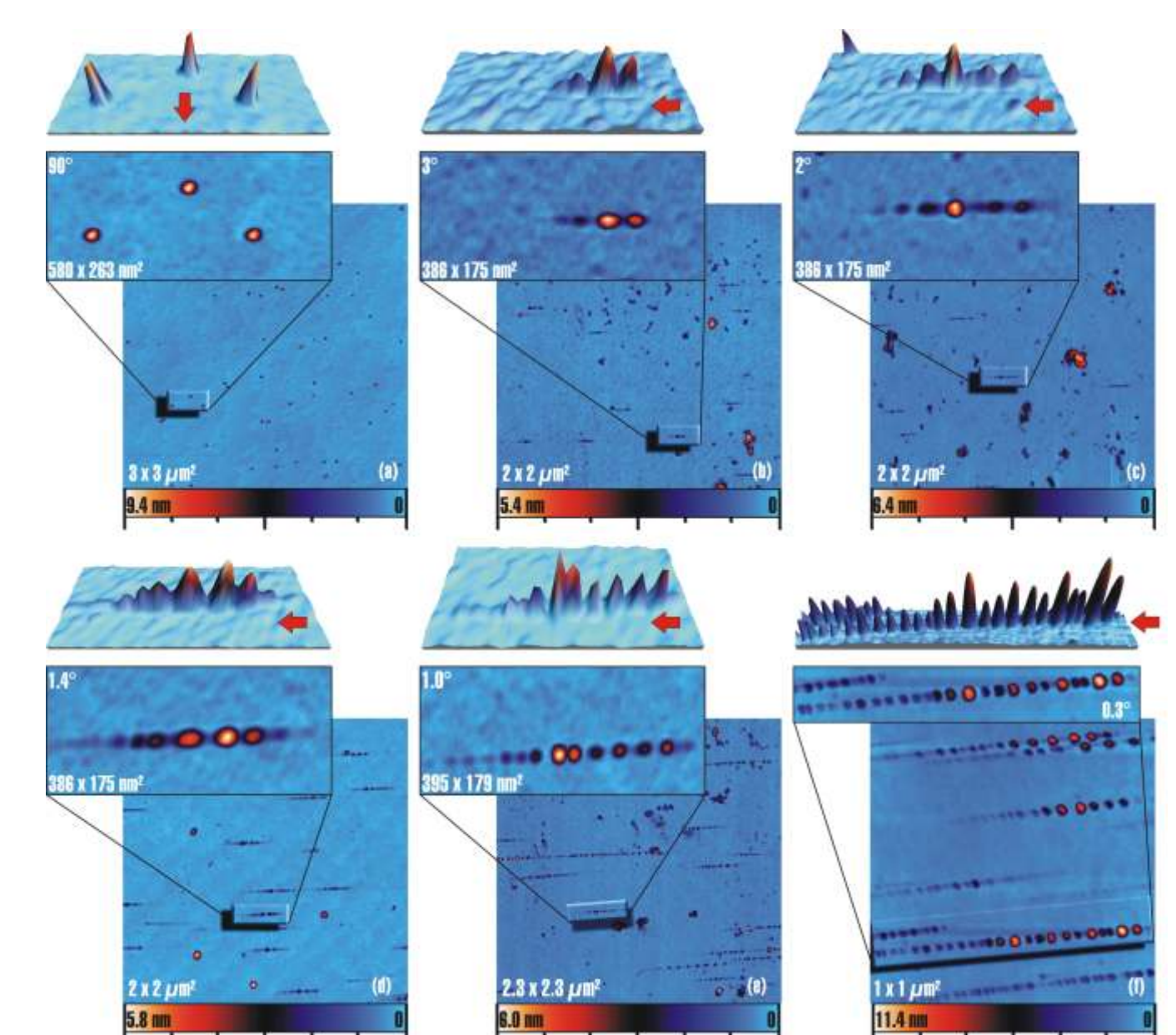


TiO₂:

- Same effect on TiO₂
- Track length different compared to SrTiO₃, depending on geometry with the same relationship to the angle of incidence: $L = d / \tan(\theta)$
- To explain the distance between hillocks the electron density must be taken into account



Calculated energy loss of Xe²⁸⁺ with 93 MeV kinetic energy in TiO₂ under 1°, polar angle 10°



References/Acknowledgement

- Fission Fragment Tracks in Semiconducting Layer Structures, L.T. Chadderton (1968)
- Electron density calculations by R. Meier, AG Entel, Uni Duisburg-Essen
- SRIM, J.F. Ziegler, J.P. Biersack, 1984-2003

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